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Unraveling the microstructural and optoelectronic properties of solution-processed Pr-doped SrSnO₃ perovskite oxide thin films

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The inorganic stannous-based perovskite oxide SrSnO₃ has been utilized in various optoelectronic applications. Facilitating the synthesis process and engineering its properties, however, are still considered challenging due to several aspects. This paper reports on a thorough investigation of the influence of rare-earth (praseodymium) doping on the microstructural and optoelectronic properties of pure and Pr-doped SrSnO₃ perovskite oxide thin films synthesized by a two-step simple chemical solution deposition route. Structural analysis indicated the high quality of the obtained phase and the alteration generated from the insertion of impurities. Surface scanning illustrated the formation of homogenous and crack-free SrSnO₃ thin films with a nanorod morphology, with an augmentation in size as the dopant ratios increased. Optical properties analysis showed an enhancement in the samples optical absorption with wide-range bandgap tuning. First-principles calculations revealed the exchange interactions between the 3d–4f states and their impact on the electronic properties of the pristine material. Hall-effect measurements revealed an immense decrement in the resistivity of the films upon increment of doping ratios, passing from $7.3 \times 10^{-2} \Omega \text{ cm}$ for the undoped sample to $4.8 \times 10^{-2} \Omega \text{ cm}$ for 7% Pr content, while a reverse trend was observed on the carrier mobility, rising from 2.5 to 7.6 cm² V⁻¹ s⁻¹ for 7% Pr content. The results emphasized the efficiency of the simple synthesis route to produce high-quality samples. The current findings will contribute to paving the way towards expanding the utilization of simple and cost-effective chemical solution deposition methods for the fast and large area growth of stannous-based perovskite oxides for optoelectronic applications.

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1. Introduction

Conventional transparent conductive oxides (TCOs) are utilized in a wide range of applications, displaying good performance and high stability. Numerous TCOs, such as ZnO, In₂O₃, and SnO₂, have been implemented in many industrial devices with a great focus on optoelectronic devices like LEDs and solar cells.^{1–3} Nevertheless, the continuous demand for superior TCOs has been constantly rising with the aim of enhancing the efficiency of these devices. Therefore, novel, alternative, and highly transparent-conducting oxide materials are required in order to satisfy the huge demand for high-performance oxides in optoelectronic applications.

Inorganic stannous-based perovskite oxides ASnO₃ (A = Ca, Sr, Ba) represent a promising range of TCO candidates receiving growing interest as a non-toxic and eco-friendly alternative to their lead-based counterparts.^{4,5} Perovskite oxides are also regarded as very attractive hosts for doping, allowing for facile engineering of the characteristics of the pristine material. Furthermore, this attractive type of oxide is considered an important class of materials to be integrated into a wide range of applications, such as in ceramic technology as components of dielectric materials and gas-sensing applications,⁶ as substrates for superconductor applications,⁷ and in solar cell applications, mainly as electrodes for photostable perovskite solar cells.^{8–11} In contrast to other perovskites, such as the manganites AMnO₃, stannate compounds add to their usefulness the absence of Jahn–Teller distortion.^{12,13}

Among the stannous-based perovskite oxides, SrSnO₃ is drawing great interest owing to its superior physico-chemical properties with enhanced performance on doping. Additionally, the constraint of larger bandgaps in this type of perovskite can be potentially overcome through the insertion of impurity elements to generate visible-light-absorbing sub-gap states. Recently, rare-earth elements have been extensively employed

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for the engineering of the properties of SrSnO₃; in particular, lanthanum (La) has been utilized in several works for the capability of achieving a higher conductivity of the material and wide bandgap tuning. La-doped SrSnO₃ thin films are considered a promising candidate in numerous applications, with a particular interest in optoelectronic devices.^{8,9}

Several doping attempts employing other rare-earth elements have been conducted to modify the characteristics of SrSnO₃.^{14–17} To the best of our knowledge, praseodymium (Pr) has never been utilized as a dopant to engineer the properties of SrSnO₃ materials. Often, the synthesis procedure followed in the growth of SrSnO₃ thin films is carried out using physical methods, including pulsed laser deposition¹⁸ and radio frequency magnetron sputtering.¹⁹ A limited number of reports have employed chemical methods; for example, the polymeric precursor method.²⁰

Commonly, the previously mentioned synthesis routes utilize a complex and multi-step growth procedure, where complex, non-practical and expensive methods are employed alongside high annealing temperature and expensive substrates. In the present study, an easy-to-manipulate and cost-effective chemical solution deposition method (spray coating) has been adopted, allowing fast deposition onto a conductive substrate (Si (100) substrate, in our case), and its effect on the quality of the as-synthesized samples has been evaluated. Above all, a high-quality orthorhombic phase was achieved at a relatively low calcination temperature (800 °C) in comparison with previous reports. A doping process was conducted to engineer the properties of the SrSnO₃ thin films using the rare-earth element praseodymium. The films were intensively characterized to identify the effect of Pr³⁺ ion insertion into the SrSnO₃ host lattice, with a particular interest in the optical and electrical properties. Moreover, a theoretical part was included to support the experimental findings by performing *ab initio* calculations based on the density functional theory. The theoretical part allowed the identification of the doping effect on the electronic properties and its eventual effect on the overall properties.

2. Experimental details

2.1 Materials

Strontium nitrate tetrahydrate (Sr(NO₃)₂·4H₂O) (molecular weight 211.63 g mol⁻¹ and purity 99.995%), tin(IV) chloride pentahydrate (SnCl₄·5H₂O) (molecular weight 350.6 g mol⁻¹ and purity 98%), praseodymium(III) oxide (Pr₂O₃) (molecular weight 329.81 g mol⁻¹ and purity 99.9%) and hydrochloric acid (HCl) (37%) were purchased from Sigma-Aldrich and used as received without further purification.

2.2 Solution preparation and thin films synthesis

The thin films were grown by a chemical deposition method that required the preparation of homogeneous and aqueous solutions by mixing 0.02 M of strontium nitrate tetrahydrate (Sr(NO₃)₂·4H₂O, 99.995% purity) and 0.02 M of tin(IV) chloride pentahydrate (SnCl₄·5H₂O, 99% purity) in 25 ml distilled water. For doping, various fractions (3, 5 and 7 at%) of

praseodymium(III) oxide (Pr₂O₃, 98% purity) (0.02 M) were dissolved in 10 ml of hot distilled water under vigorous magnetic stirring with the addition of 5 ml of hydrochloric acid (HCl). The two solutions were mixed under vigorous magnetic stirring at 70 °C for 2 h, resulting in very clear solutions. The solutions were transferred to the deposition chamber equipped with the ultrasonic spray set-up (SONAER Ultrasonics) set at a frequency of 130 kHz and an applied power of 2.8 W.^{20–22} The selected substrates were the silicon wafer Si (100) with the dimensions of 1–1.5 cm. The substrates were ultrasonically cleaned with distilled water, ethanol and acetone consecutively for 15 min and finally dried in an air stream. The solution flow rate was fixed at 0.9 ml min⁻¹ and compressed air was used as the carrier gas. The substrates were placed horizontally on the surface of the hot plate at a distance of 12 cm below the spray nozzle. The hot plate was initially heated at a slow rate to reach 250 °C with the temperature controlled by a thermocouple. Multiple attempts were performed to reach the optimal temperature conditions. Finally, the prepared films were placed in a furnace and calcined in air at 800 °C for 1 h at steps of 15 °C min⁻¹ to reach the correct phase as shown in Fig. 1.

2.3 Characterization

2.3.1 Structural analysis. The crystallographic phase and phase purity were investigated by means of X-ray diffraction (XRD) on the as-synthesized oxide thin films after the calcination process. The XRD scan was recorded using a Bruker D8 Discover Advanced Diffractometer with Cu K α radiation at a wavelength of $\lambda = 0.154056$ nm. The sample stage was rotated at 15 rpm. The spectra were taken for a duration of 2 h. The values of 2θ varied in the range of 10°–70° with steps of 0.008° and an integration time of 0.25 s.

2.3.2 Raman and FT-IR measurements. Raman data were recorded at room temperature using a Raman spectrometer microscope (DXR2; Thermo Scientific) with a laser excitation wavelength of 633 nm. The measurements were collected from 100 to 800 cm⁻¹. The transparency of the films was collected by Fourier transform infrared spectroscopy (FT-IR) (FT/IR-4600 (FTIR-ART); JASCO) recorded in the range of 450–4000 cm⁻¹.

2.3.3 Scanning electron microscopy (SEM). Surface scanning, compositional analysis and atomic mapping were performed to observe the morphology of the resulted surfaces and to measure the ratios of each element by field emission scanning electron microscopy (FE-SEM, Quattro S FEI), alongside

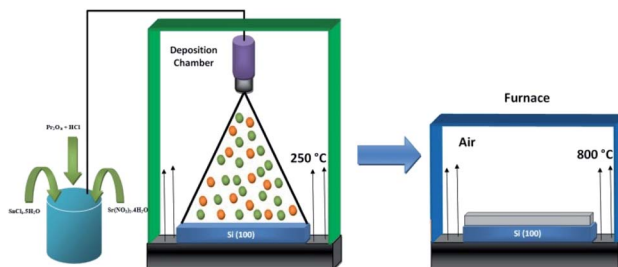


Fig. 1 Schematic illustration of the deposition set-up with the different steps followed.



energy dispersive X-ray spectrometry (EDX; Hitachi) at 100 kV accelerating voltage. Atomic mapping was also performed to quantify the distribution of each element on the film surfaces.

2.3.4 UV-vis spectroscopy. The optical properties were investigated by measuring the optical absorbance spectra using a UV-Vis spectrophotometer (Lambda 900 UV/VIS/NIR Spectrophotometer) with the wavelength ranging from 250 nm to 1200 nm recorded in the absorption mode.

2.3.5 Hall-effect measurements. The electrical properties of the films were measured using an ECOPIA Hall-effect measurement system in the van der Pauw configuration collected at room temperature (300 K) in the presence of a magnetic field.

3. Computational methods

First-principle calculations in the present work were performed *via* density functional theory (DFT) using the Korringa–Kohn–Rostoker (KKR) method with the coherent potential approximation (CPA). The extremely correlated 4f-related electronic states of Pr were modulated by the self-interaction corrected (SIC) approach developed by Toyoda.²³ The (SIC) approach is normally utilized to acquire a more realistic description of the disordered local moments of the materials under investigation as indicated before.^{20,22} For the parameterization of the exchanged energy, local density approximation (LDA) was employed using SIC included in the KKR-CPA-SIC-LDA package as implemented in MACHIKANEYAMA2002.²⁴ Also, 500 *K*-points in the whole first Brillouin zone were taken into account and the scalar relativistic approximation was incorporated as well. The SIC-LDA approximation allows a precise calculation in comparison to the conventional LDA approximation, resulting in an amelioration of the photoemission spectra. For the doped calculations, a fraction of Sr atoms was replaced by Pr atoms randomly. The electronic valence configurations for each element were: Sr-4s²4p⁶5s², Sn-4d¹⁰5s²5p², O-2s²2p⁴ and Pr-4f³6s². Total energy minimization was performed using the appropriate unit cells of an orthorhombic lattice with the space group *Pbnm*. In the current calculations, we fixed the parameters *v* and *b/a*, which were determined by the geometry. The internal parameters *u* and the *c/a* ratio were obtained by the energy minimization for the pure SrSnO₃ compound and were fixed for Sr_{1-x}Pr_xSnO₃ alloys. All the calculations were performed at *T* = 0 K from the total energy fitted to the Murnaghan equation. In the current calculations, the theoretical calculations were restricted to just one-unit cell since an idealized solid exhibits perfect periodicity as long as the bulk properties are considered. The lattice vibrations, finite temperature effects and relativistic corrections were not considered in the current work. The electronic and optical properties of the pure and Pr-doped SrSnO₃ were calculated in a stable orthorhombic structure that conformed also to the *Pbnm* space group.

4. Results and discussion

In order to evaluate the quality of the prepared films, a thorough and profound structural analysis was performed. Fig. 2a

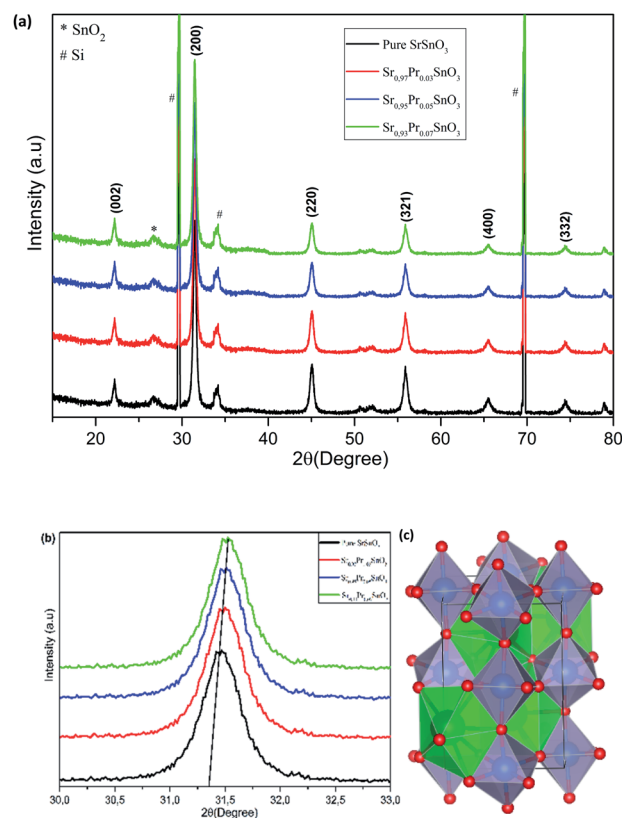


Fig. 2 (a) XRD patterns for pure and Pr-doped SrSnO₃ thin films deposited on Si (100) substrate and annealed at 800 °C. (b) Magnified XRD peaks in the region of the (200) plane. (c) Crystal presentation of SrSnO₃ crystallizing in the orthorhombic structure with the *Pbnm* space group (color code: Sr = black, Sn = blue, O = red).

presents the XRD patterns of the pristine SrSnO₃ films deposited on Si (100) substrate and annealed at 800 °C. The results revealed that all the films had a polycrystalline structure with all the major peaks located at 22.2°, 31.42°, 45.12° and 55.95° associated with the (*hkl*) planes of (002), (200), (220) and (321), respectively. All corresponded to the orthorhombic structure of SrSnO₃ with the *Pbnm* space group (Fig. 2c), matching correctly to the standard JCPDS data (PDF no: 77-1798). Consequently, the simple procedure followed in the present work allowed the growth of high-quality films. A minor peak was detected related to SnO₂ impurity, alongside one weak and two strong peaks assigned to the Si (100) substrate. One could observe that the peaks related to substrates were very strong, which may be attributed to the low thicknesses of the deposited films. The results confirmed that the type of substrate employed had no significant effect on the quality of the phase. A preferential orientation along the (200) plane for the pristine sample was observed. After the doping ratios were induced, the same peaks were collected attached to the ones of the silicon wafer substrate. The quality of the patterns and the intensity of the peaks were also affected by the doping, where a slight decrease in the intensity of the peaks was observed, which may be due to the internal defects and stain induced by the incorporation of the Pr³⁺ ions into the pristine lattice. The slight shifting of the



peaks towards higher angles indicated that the crystallographic positions of Sr^{2+} ions had been successfully occupied by the trivalent Pr^{3+} ions in the SrSnO_3 host lattice and strain had developed in the lattice, as indicated in Fig. 2b.

The lattice parameters were calculated to determine the crystallographic defects on the orthorhombic pristine structure and the impact of doping fractions on the lattice parameters distortion by means of the following equation:

$$\frac{1}{d^2} = \frac{h^2}{a^2} + \frac{k^2}{b^2} + \frac{l^2}{c^2} \quad (1)$$

Fig. 3 illustrates the variation of the calculated parameters as a function of the dopant content. The values for the pristine sample matched correctly with previously reported results for the SrSnO_3 orthorhombic structure.^{17,25} It was noticeable that the substitution of Sr^{2+} by the Pr^{3+} in the SrSnO_3 pristine structure generated strain along all the axis, as indicated in Fig. 3a. The lattice parameters (a , b and c) showed the same trend, where the lattice constants were increased upon Pr addition. This decrease may be attributed to various factors, such as the concentration of the dopant, defects (vacancies, interstitial, dislocation), external strain developed due to calcination temperature and the difference between the ionic radii of Pr^{3+} (1.18 Å) compared to Sr^{2+} (1.44 Å), which should result in compression in the pristine lattice. However, the experimental values showed the opposite, this may be due to the partial substitution of Sn^{4+} by Pr^{4+} (coordination = 6) ($r(\text{Sn}^{4+}) = 0.69$ and $r(\text{Pr}^{4+}) = 0.85$), which allowed an increase in the lattice parameters as indicated earlier through the decreasing intensities. The structure remained orthorhombic and was not tailored by the insertion of different ratios of Pr^{3+} into the SrSnO_3 lattice. The crystalline size was calculated using the Debye-Scherrer's formula:

$$D = \frac{0.9\lambda}{\beta \cos \theta} \quad (2)$$

where β is the observed angular width at half maximum intensity (FWHM) of the corresponding peak, λ is the X-ray wavelength (0.15406 nm for $\text{CuK}\alpha$) and θ is Bragg's angle. Fig. 3b illustrates the variation of the full width at half maximum (FWHM) and the grain size as a function of the doping content. The FWHM of the main reflection (200) became narrower as the dopant fraction increased, generating an augmentation in the crystallite size in the various samples. This variation indicated that the doped thin films were comprised of crystallites of different sizes and possessing higher crystallinity as the doping ratio increased. Another noteworthy observation was the augmentation in the crystallites size showing a reverse trend from the FWHM. This augmentation will result in a significant impact on the optoelectronic properties of the films, mainly on the transport properties.

Vibrational analysis of the material under investigation is essential to emphasize the purity and crystallinity of the prepared samples and to identify the dopant insertion effect on the vibrational modes of the pristine structure. Therefore, this part consisted of an in-depth analysis of the samples employing both FT-IR and typical Raman analysis at room temperature. The FT-IR analysis results of the films with different concentrations of Pr recorded at room temperature within the region of 450–2000 cm^{-1} are shown in Fig. 4. The orthorhombic phase of SrSnO_3 with the $Pbnm$ space group had 25 IR active modes at Γ of the Brillouin zone, given by the irreducible representations:

$$\Gamma_{\text{IR}} = 9B_{1u} + 7B_{2u} + 9B_{3u} \quad (3)$$

The undoped sample showed multiple modes at different positions, starting with the widest one at 1464 cm^{-1} , which was attributed to the N–O band linked to the nitrate present in the precursors. The bands between 2800 and 3000 cm^{-1} were assigned to different types of O–H stretching. The band at 1033 cm^{-1} was attributed to the asymmetric stretching

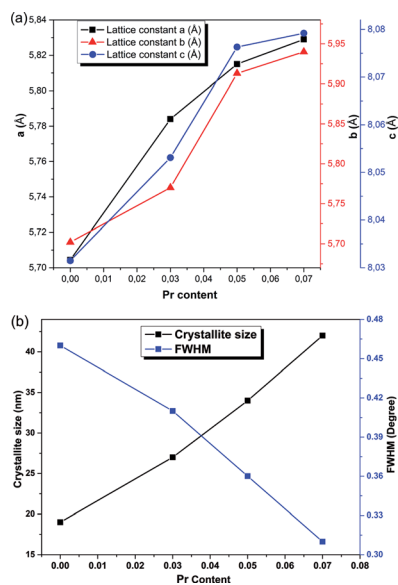


Fig. 3 Calculated parameters of the pure and Pr-doped SrSnO_3 . (a) Lattice constants and (b) crystallite size and FWHM variation as a function of Pr content.

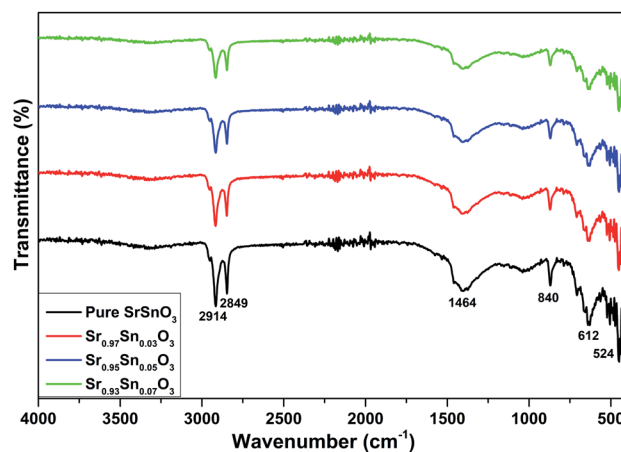


Fig. 4 FT-IR spectra of the $\text{Sr}_{1-x}\text{Pr}_x\text{SnO}_3$ ($x = 0, 3, 5$ and 7 at%) thin films.



vibration of Sn–OH bonds, while the bands located at 840 cm^{-1} were attached to O–Sn–O asymmetric stretching vibration of SnO_3 . The band at 612 cm^{-1} was due to the presence of stannate (SnO_3^{2-}) vibrations.²⁶ The peak located at 524 cm^{-1} was attached to the presence of stretching vibrations of Sn–O bands, and this trend confirmed the existence of SnO_6 octahedral tilting in all the compounds.^{27,28} Several extra weak peaks appeared between 400 and 500 cm^{-1} and were associated with the Pr–O molecular vibrations originating from the octahedral coordination PrO_6 . Indeed, the FT-IR analysis results confirmed the presence of metal–oxygen vibrations with the detection of other active IR modes, which was consistent with the XRD analysis and confirmed the effective formation of the SrSnO_3 compound in the orthorhombic structure.

Raman analysis of the samples collected at room temperature was performed to determine the local structure of the samples, to better inspect the presence of secondary phases, and to identify the Pr doping effect on the vibrational modes of the pristine structure, as presented in Fig. 5. According to previous extensive Raman analysis, the orthorhombic phase of SrSnO_3 has 24 active Raman modes presented as follow:

$$\Gamma_{\text{Raman}} = 7A_g + 5B_{1g} + 7B_{2g} + 5B_{3g} \quad (4)$$

The equation contains four antisymmetric with two symmetric octahedral stretching modes, four bending modes, and six octahedral rotation or tilt modes. The remaining eight modes are associated with the strontium cations. The Raman analysis of the undoped SrSnO_3 thin film revealed several vibrational modes with two intense peaks located at 225 and 256 cm^{-1} , corresponding both to the A_g mode.²⁶ Multiple other peaks were detected at 111 , 145 , 160 , 402 and 634 cm^{-1} and also matched with the usually recorded Raman modes for orthorhombic ($Pbnm$) SrSnO_3 .^{26,29} All these modes were due to the first-order Raman scatterings, which is a signature of distortion from the ideal cubic perovskite because, in ideal perovskites, no first-order Raman scattering is possible.¹³ As the dopant ratios

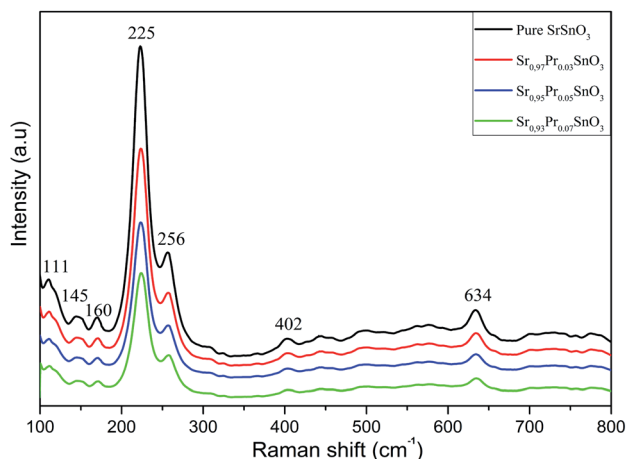


Fig. 5 Raman spectra of the pure and Pr-doped SrSnO_3 thin films collected at room temperature.

were inserted, a slight shifting in position was observed, particularly for the main modes. The A_g active mode for the doped samples showed a slight shift towards a higher wave-number (231 cm^{-1}) when compared to the undoped film (225 cm^{-1}). This revealed that the Pr^{3+} cations had effectively replaced the Sr^{2+} sites and consequently affected the Sr–O bonds. No change in modes was observed. Thus, the doping process had no effect on changing the modes or altering the structural properties of the pure sample. Furthermore, an intense decrement of the modes intensities was observed with a slight fading of the smaller modes. The Raman analysis, thus, further authenticated the formation of the orthorhombic SrSnO_3 ($Pbnm$) compound with high crystallinity.

Morphological properties scanning is a substantial step in evaluating the quality of prepared samples and thereby their effect on the stacking and construction of the anticipated devices. Hence, a full thorough scanning of the surface quality was performed by means of field emission scanning electron microscopy (FE-SEM) alongside energy dispersive spectroscopy (EDX) to evaluate the modifications induced by Pr doping on the quality, grain size and composition of the films. Fig. 6 exhibits the FE-SEM images of the pure and Pr-doped SrSnO_3 films deposited onto Si (100) substrate and annealed at $800\text{ }^\circ\text{C}$. Fig. 6a displays a top-view image of the prepared film. The samples generally possessed textured, crack-free and homogeneous surfaces with a uniform distribution along the substrate. The image manifests the efficiency of the synthesis route followed in

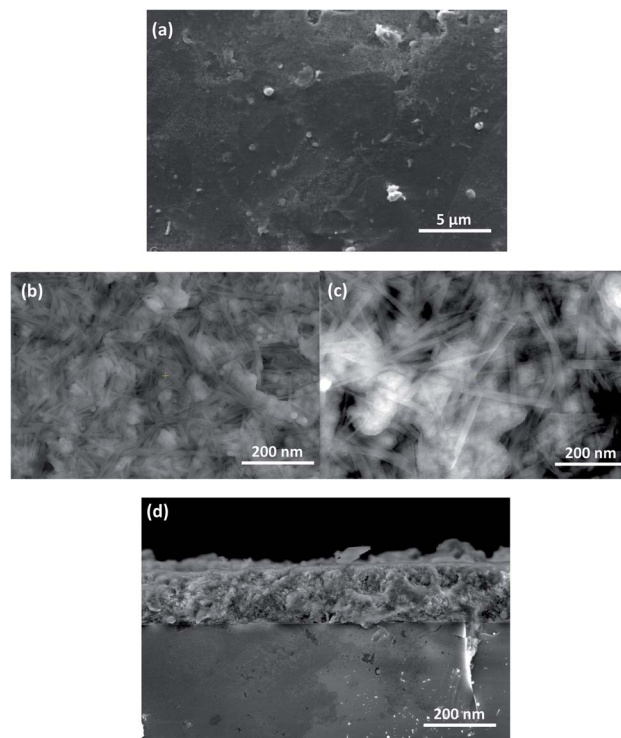


Fig. 6 FE-SEM scanning images for the pure and Pr-doped SrSnO_3 nanorod thin films. Top view of the films (a) and close view (b) of the pure and (c) 7% (Pr content) doped films. (d) Cross-sectional view of the deposited films.



producing high-quality and uniform films. Moreover, the micrograph in Fig. 6b displays the formation of high-density nanorods with varying sizes for the pure film. It is noticeable from the images that small spherical grains were formed, which may be attributed to the limited number of Sr and Sn clusters and secondary phases. By increasing the dopant content, an augmentation of the size of the nanorods was observed and the size continued to increase as the dopant fraction increased, as presented in Fig. 6c. This augmentation demonstrated the effective insertion of Pr ions in SrSnO₃ pristine lattice, as mentioned earlier in the structural analysis results, indicating the correlation between the structural and morphological results. Fig. 6d displays a cross-sectional view of the prepared films. The thicknesses of the films were measured as being between 180 and 200 nm, indicating the high quality of the prepared samples and their compatibility for facile device stacking.

EDX analysis and atomic mapping were performed to analyze the compositional elements of the prepared samples and the distribution of the elements along the prepared surfaces. Fig. 7a illustrates the EDX data collected for the pure and doped samples. The results confirmed the presence of sufficient quantities of the main elements (Sr, Sn, O), indicating the high purity and near-stoichiometric nature of the samples with a rich oxygen content. The detected Si signal was assigned to the Si (100) substrate as a result of the difference between the

Table 1 Atomic concentrations of the different Sr_{1-x}Pr_xSnO₃ samples obtained by EDX analysis

Samples	Atomic percentages			
	Sr	Sn	O	Pr
SrSnO ₃	23.93	24.21	51.86	0
SrSnO ₃ :Pr ³⁺ (3%)	23.73	24.19	51.28	0.8
SrSnO ₃ :Pr ³⁺ (5%)	23.49	24.24	51.07	1.2
SrSnO ₃ :Pr ³⁺ (7%)	23.37	24.22	50.71	1.7

thicknesses of the films and the high EDX interaction volume and penetration depth of the electron beam. This may slightly reduce the accuracy of the EDX quantitative analysis. Furthermore, the existence of the dopant element Pr was confirmed in the doped films with the variant ratios added as gathered in Table 1. The stoichiometry was slightly unbalanced as the dopant ratios increased. Furthermore, elemental atomic mapping was implemented to further probe the distribution of the elements along the surfaces and their quantification with high precision. The mapping images confirmed the presence of the main elements with equal distribution along the surfaces of films. In addition, the images show an orderly repartition of the elements with a higher concentration for the oxygen element and a small fraction for the Pr element.

Since rare-earth elements are well known as an effective dopant commonly used to engineer the optical properties of metal oxides, the optical properties of the films were collected to assess the trivalent Pr³⁺ insertion effect on the absorption and band gap tuning of the pristine film. Consequently, the UV-Vis-NIR absorption spectra of the pure and Pr-doped SrSnO₃ thin films are illustrated in Fig. 8a. All the films exhibited strong absorption in the UV light region (200–400 nm), with a notable decrement in the visible region, which continued to decrease exponentially as the wavelength value increased in the near-infrared (NIR) region. The absorption edge of the doped films

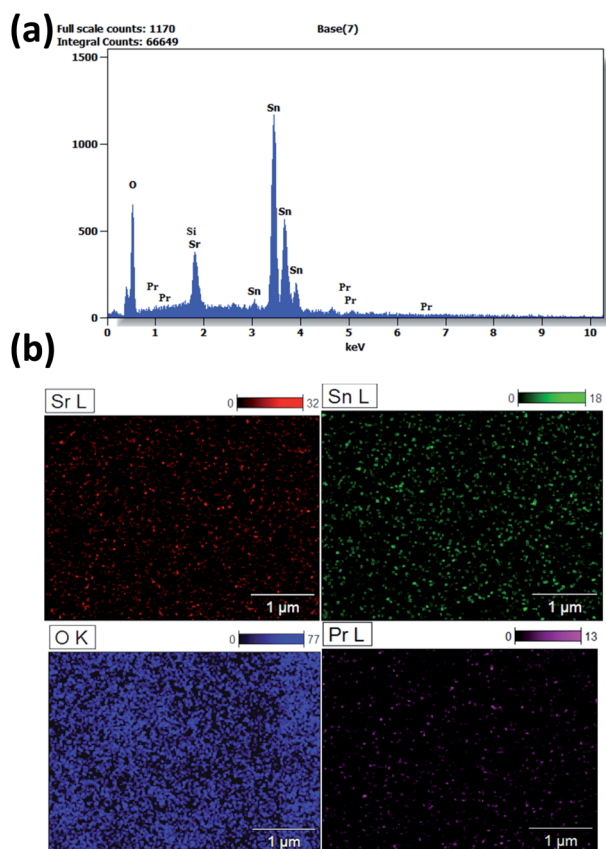


Fig. 7 (a) EDX analysis spectrum and (b) atomic mapping (Sr, Sn, O, Pr) images of Pr-doped SrSnO₃ thin films.

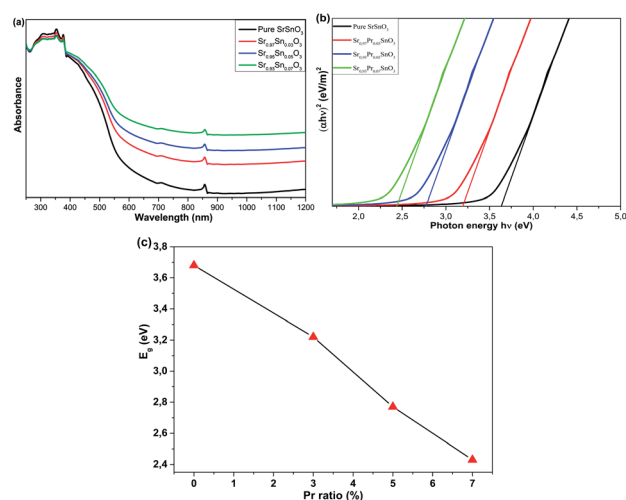


Fig. 8 (a) Optical absorbance as a function of the wavelength. (b) The plots of $(ah\nu)^{1/2}$ versus $h\nu$ and (c) band gap variation of the pristine and Pr-doped SrSnO₃ thin films.



was slightly shifted towards higher wavelengths as the Pr fractions increased. In addition, the dopant incorporation caused the absorption to decrease in the UV light region and increase in the visible region and onward, showing a reverse trend from the undoped film. The results manifested the effect of Pr³⁺ insertion on tuning the optical properties of metal oxide materials, which has been reported before.¹⁷ It could be clearly seen that the doping process enhanced the photon-absorption ability of the films in the visible and near-infrared region, which is quite suitable for optoelectronic applications. To further evaluate the doping effect on the band gap of the samples, the band gaps of the pristine and Pr-doped SrSnO₃ were calculated using a Tauc plot:

$$(\alpha hv) = A(hv - E_g)^n \quad (5)$$

where A is a constant, h is Planck's constant, hv is the incident photon energy and n is a number related to the electronic transition nature between the conduction and valence bands of the material. The number n can have various values, which are 1/2, 2, 3/2 and 3 for allowed direct, allowed indirect, forbidden direct and forbidden indirect transitions, respectively. Previous extensive experimental and theoretical works including the present paper have indicated that SrSnO₃ is a directed band semiconductor,²⁷ meaning that $n = 1/2$. The optical band gap was extracted by extrapolating the linear part of the $(\alpha hv)^2$ vs. hv curve to the energy axis, when $(\alpha hv)^2 = 0$ as plotted in Fig. 8b. The band gap for the pristine sample was estimated at 3.67 eV, which is consistent with previous works reporting the preparation of SrSnO₃ thin films corresponding to the orthorhombic phase. The slight difference in the value of the band gap may be attributed to the thickness of the prepared sample. The band gap variation values as a function Pr doping ratios are plotted in Fig. 8c. Similar to the earlier observation for the optical absorption, the band gap decreased as the first percentage was added and stabilized at 2.43 eV for 7% Pr content. The UV-vis analysis results indicated the capability of praseodymium to improve the optical absorption of the prepared samples by enhancing their optical absorption and tuning the band gap, which were in good agreement with the results collected from the XRD and FE-SEM analysis regarding the nanorods size augmentation and quality enhancement of the films.

This part consists of theoretical calculations that were mainly carried out to uncover the nature of the bonds formed between the different elements and to investigate the electronic and optical properties of the material under investigation. Herein, the calculations were conducted in order to strengthen the experimental findings regarding the properties of the pristine material and to inspect the effect of the strongly correlated 4f state of Pr insertion on the electronic and optical properties of the SrSnO₃ perovskite compound. Therefore, the results from first-principle calculations will permit an overall assessment of the alterations on the properties of the material under investigation. Fig. 9 exhibits the projectile and total density of states of the pure and Pr-doped SrSnO₃ compounds calculated using LDA and SIC-LDA approximations as a function of energy. For the dos produced by regular LDA, the conduction band minima (CB) of SrSnO₃ is composed essentially of Sr-3d states and

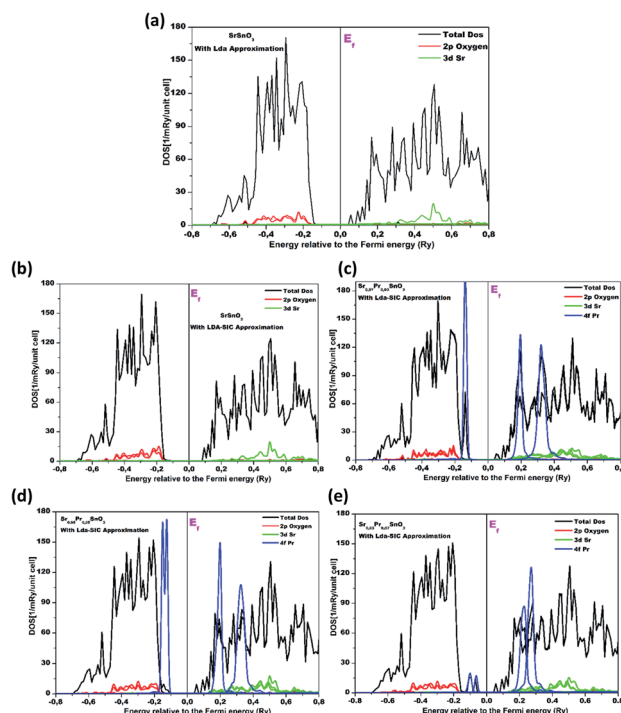


Fig. 9 Calculated partial and total density of states of the pure and Pr-doped SrSnO₃ (a) 0% with LDA approximation, and (b) 0% with LDA-SIC. (c) 3%, (d) 5% and (e) 7% Pr content.

a negligible contribution from O-2p, while the valence band maxima (VB) is largely dominated by the O-2p states. The calculated band gap was estimated at 2.46 eV. Commonly, regular LDA approximation usually tends to underestimate the optical and electronic properties of the material under investigation, leading to the non-consideration of the exchange and the correlation effects in metal oxide materials and causing important self-interaction errors.³⁰ This underestimation of the band gap by LDA is due to the lack of a discontinuity in this exchange–correlation potential. Thus, the self-interaction correction (SIC) was integrated to enhance the accuracy of the obtained properties. LDA-SIC approximation is generally viewed as an extension of regular LDA, where the Kohn–Sham wave function is projected onto a set of localized basis orbital's and the SIC approximation is governed by the energy difference between the energy gain due to hybridization of the orbital with the valence band and the energy gain upon localization of the orbital.³¹ After the SIC correction, the band gap increased to reach 3.12 eV as expected. Typically, doping a semiconductor obligates the Fermi level to shift towards higher energy values due to the fact that the doping process enhances the stability of the compound corresponding to the low energies. Plus, the Fermi energy shifts towards the conduction band after doping and this is due to the fact that the valence band shifts into the lower energy region much more than that of the conduction band. The application of SIC approximations permitted properly dealing with the 4f states in SrSnO₃ lattice doped with the rare-earth (RE = Pr) compound due to the existence of f-electrons. As for the SIC-LDA approximation, the same applies to the conduction band, with growing domination from the O-



2p states spotted in the valence band, as can be seen from Fig. 9. After the first doping percentage was inserted, a major contribution from the Pr-4f states was observed, especially in the valence band, and the band gap decreased to 2.53 eV. For the 7% Pr content, we can notice that the contribution of the Pr-4f states increased and dominated both the valence and conduction bands, leading the band gap to shrink and further reduce to 2.12 eV. This decrease in the band gap was mainly attributed to the 3d–4f strong exchange interactions. Previous works reporting rare-earth doping indicated a similar outcome; for instance, Abdul Majid *et al.* reported that the 3d–4f exchange interactions are more fragile than 3d–3d because of the strongly localized nature of 4f orbitals in rare-earth atoms.³² A first proposition that provided an explanation of 3d–4f interactions was suggested by Campbell.³³ Similar to that, Brooks *et al.* further discussed in detail how 4f localized electrons polarize 5d states, which then interact with 3d orbitals.³⁴ Indeed, the DFT calculations permitted an accurate and overall analysis of the electronic and optical properties of the pristine compound alongside inspecting the effect of the rare-earth (praseodymium) doping on engineering its properties in a constructive manner. The results confirmed the fact that the Pr³⁺ incorporation enhanced the optical and electrical properties of the samples.

Assessing the electrical properties of thin film materials and the defects generated from impurities insertion is essential to evaluate their potential for optoelectronic applications. Therefore, it is important to conduct a thorough evaluation of the electrical properties of the prepared samples and the alterations resulting from the doping process, thereby evaluating their potential for further applications. The electrical properties of the pure and Pr-doped SrSnO₃ thin films were collected at $T = 300$ K to unveil the semiconducting nature of the films, and to examine the alterations on the conductivity and carrier mobility generated from the Pr³⁺ doping effect. Fig. 10 displays the collected electrical properties employing the van der Pauw configuration in the presence of a magnetic field and their variation as a function of doping content. The values of the Hall coefficient (R_H) indicated that all the samples had n-type

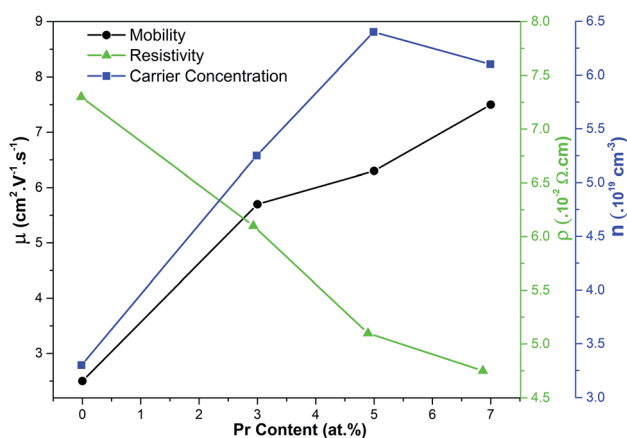


Fig. 10 Electrical properties (resistivity, carrier concentration, and mobility) of the pure and Pr-doped SrSnO₃ films as a function of Pr content collected at room temperature.

conductivity, as indicated previously.^{16,17} As for the films resistivity, an immense decrement was observed upon the doping ratios increase passing from $7.3 \times 10^{-2} \Omega \text{ cm}$ for the undoped sample to $4.8 \times 10^{-2} \Omega \text{ cm}$ for 7% Pr content. This proves once again that rare-earth element doping (in our case praseodymium) is effective in enhancing the conductivity of oxide thin film materials. For the carrier concentration, a reverse tendency to the resistivity was detected, where the value for the undoped sample jumped from 3.4×10^{19} to $6.1 \times 10^{19} \text{ cm}^{-3}$ for 7% Pr content. The same variation was noticed on the carrier mobility, which increased from 2.5 to $7.6 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$. The increment of the carrier mobility by the doping insertion effect was suggested earlier by the structural results and FE-SEM scanning by the augmentation in the nanorod sizes. Thus, the Pr-doped SrSnO₃ thin film possessed superior electrical properties in comparison to the pristine material, showing the capability of Pr³⁺ as a dopant to enhance the characteristics of stannous-based perovskite oxides.

5. Conclusions

In summary, a facile, two-step route was developed to synthesize high-quality Pr-doped SrSnO₃ onto a Si (100) substrate as highly conductive and transparent oxide thin films *via* a simple chemical solution method. Microstructural analysis revealed that the increase in Pr substitution at the Sr sites enhanced the phase quality and fostered its stability. Plus, the type of substrate used had no effect on the quality of the phase. Morphological scanning revealed the nanorod nature of the samples and the constructive effect of the Pr doping ratios on the quality of the films. An increment in the films optical absorption was noticed as the doping content increased together with wide band gap tuning. First-principle calculations allowed the identification of extremely correlated 4f-related electronic states (with the Pr) effect on the SrSnO₃ electronic and optical properties. Hall-effect measurements showed an increment in the carrier mobility and a decrease in the resistivity with superior characteristics as the doping fractions increased. Overall, the facile synthesis route, tunable properties, enhanced optical absorption and electrical properties of the nanorod morphology Pr-doped SrSnO₃ thin films are encouraging for future integration in optoelectronic applications.

Conflicts of interest

There are no conflicts to declare.

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